

# **Advancing Front-end Readout ASICs with BiCMOS SiGe Technology for Ultra-Fast Sensors**

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## **Research Topic**

**Development of Advanced Front**end Electronics

For Monolithic and Hybrid **Pixel Detectors** with HVCMOS, SPAD, SiPM and THz sensors

with high time resolution

#### For Applications in

astro-particle physics beam diagnostics particle physics

#### Main Focus in Design of

preamplifier and comparator time to digital converter (TDC)

## Challenges

**Developing Pixel Detector ASICs** 

Pixel Detectors with High Time **Resolution need** needs high speed circuits Iow power consumption

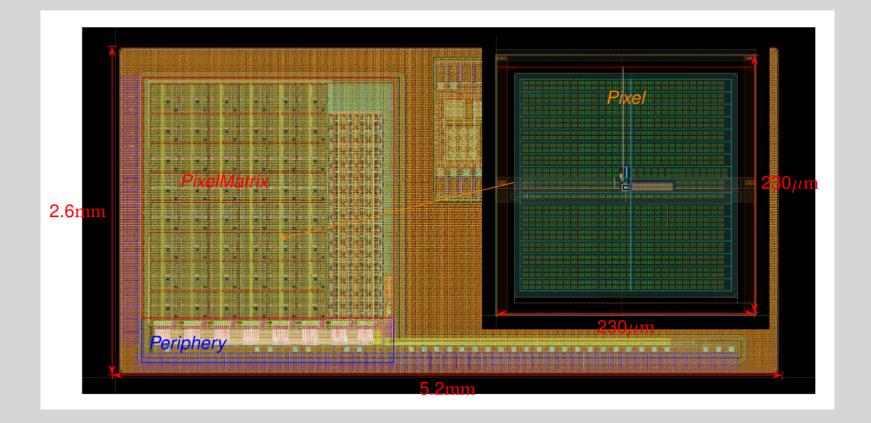
#### Routing and Design Rule Restrictions

- technology-depended
- number of design rules increases dramatically for advanced nodes
- e.g. polysilicon filling rules vs. pixels with small charge collection nodes

#### Reliability in Difficult Environments

## Latest Development

## PicoPix1



High Voltage Monolithic Active Pixel Sensor (HV-MAPS)

expected time resolution below 100 ps • two different flavors of pixels

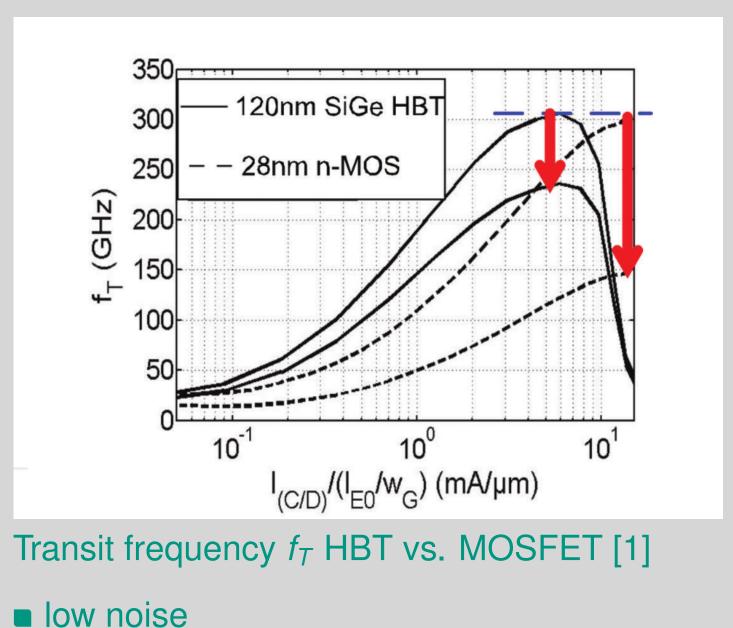
- digital readout
- $\rightarrow$  mixed-signal ASIC design

high radiation in particle detectors Iarge temperature variations for surface-based astroparticle detectors

Iarge N-well small N-well

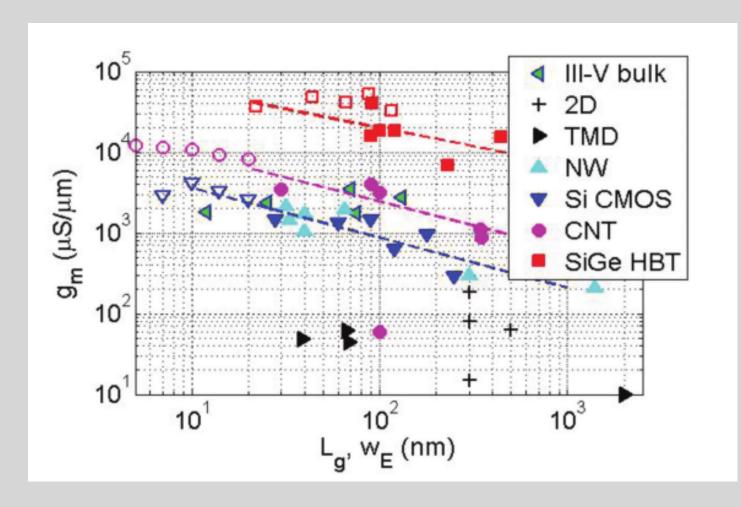
# **A Solution: Heterojunction Bipolar Transistors (HBT)**

- High time resolution requires:
- fast Amplifiers = high  $f_T$



Pixelated design requires:

### Iow area consumption



 $g_m$  vs. area of different technologies [1] Iow power consumption

# **Our Process:**



IHP SG13G2 130 nm SiGe BiCMOS[2]

- IHP is a research institute working closely together with KIT
- IHP offers the SiGe HBTs with highest  $f_T$  $f_T / f_{max} = 300 \,\text{GHz} / 500 \,\text{GHz}$
- triple-well process available
- PDK for Cadence Virtuoso design environment
- already used for pixel sensors with high time resolution[3]

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#### References

- [1] N. Rinaldi and M. Schröter, Silicon-Germanium Heterojunction Bipolar Transistors for mm-Wave Systems: Technology, Modeling and Circuit Applications -. Aalborg: River Publishers, 2018, ISBN: 978-8-793-51961-9. DOI: 10.13052/rp-9788793519602.
- [2] H. Rücker, B. Heinemann and A. Fox, "Half-terahertz sige bicmos technology," in 2012 IEEE 12th Topical Meeting on Silicon Monolithic Integrated Circuits in RF Systems, 2012, pp. 133–136. DOI: 10.1109/SiRF.2012.6160164.
- [3] L. Paolozzi. "Design of sige bicmos monolithic pixel sensors with picosecond-level time resolution." (2019), [Online]. Available: https://indico.fnal.gov/event/22290/ contributions/66878/attachments/42092/50885/2019 12 06 Fermilab cut.pdf (visited on 02/11/2021).

